Title

Electrically actuated phase-change pixels for transmissive and reflective spatial light modulators in the near and mid infrared

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Abstract

An electrically actuated layer of phase-change material (PCM) was employed to build the transmissive and reflective spatial light modulators, the PCM was sandwiched between N-droped Si or indium tin oxide layers.

Work at 1.55 (to 2.10) μm , that is, near- and mid- infred region.

Focus on modulating and switching free-space light.

Conclusion

 $1.55~\mu m$ wavelength where 0.7 dB IL and 27 dB C(R) are found in reflective SLMs as compared to 4.5 dB IL and 32 dB C(T) in transmissive SLMs. For both S and P polarization the simulated performance was relatively insensitive to angle variation in the 0° to 25° range

SIMULATIONS OF INDIVIDUAL TRANSMISSIVE SLM PIXELS

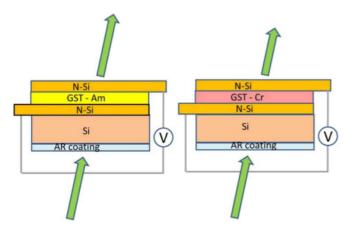
N-doped Si's donor concentration: $1\times 10^{19}\,cm^{-3}$

Corresponding refractive index of Si: 3.4807+0.0015i at $1.55\,\mu m$ GST layer index: 4.60+0.12i (amorphous), 6.98+1.84i (crystalline)

Thickness of GST laver: 100 to 500 nm

Thickness of doped semiconductor layer: 200 or 500 nm

Structure of device:



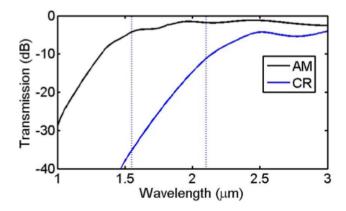
Performance with different parameters:

Table 1. Transmitted Intensity and Contrast Ratio in Decibels at 1.55 $\mu m,\,Normal$ Incidence

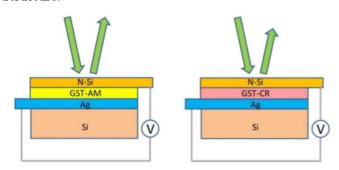
SLM Parameters	T(am)	T(cr)	C(T)
500 nm GST, 200 nm n-Si	-4.6	-37.0	32.4
500 nm GST, 500 nm n-Si	-4.3	-36.3	32.0
500 nm GST, 200 nm ITO	-4.3	-36.6	32.3
500 nm GST, 500 nm ITO	-3.8	-37.4	33.6

SIMULATIONS OF INDIVIDUAL REFLECTIVE SLM PIXELS

N-doped Si's donor concentration: $1\times 10^{19}\,cm^{-3}$ Performance at optimal parameter:



Structure:



Highlight

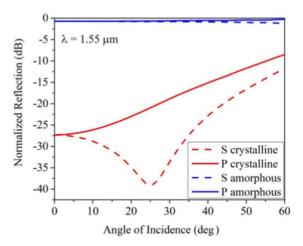
Electrical control means that the PCM is sandwiched between two transparent conductors with voltage applied across the conductors. An applied field or current of suitable duration and strength then induces the desired phase change. Advantageously, the PCM film is stable, or self-holding, in either phase. External electric power is utilized only during the brief time of phase transition. The optical properties of the two phases differ rather dramatically, and this optical difference has a variety of important applications.

An antireflection (AR) layer is useful in the transmissive SLM, while in the reflective SLM a metallic mirror layer replaces one of the transparent conducting layers.

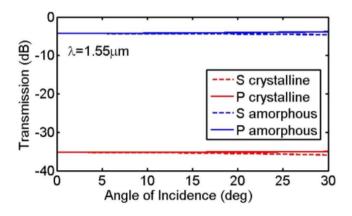
In the present work, we assume that the PCM layer is divided into a two-dimensional (2D) N × M array of small pixel areas that are electrically addressed as individuals. Addressing would be done by structuring both electrical layers that contact the PCM. The front-plate contact is divided into electrically separate X_i stripes, while the rear-plate contact has orthogonal Y_j stripes, where i = 1...N and j = 1...M, thereby providing $X_i - Y_j$ addressing of individual pixels in the PCM layer.

Performance at different incidence angles

Calculated reflectivity as a function of incidence angle for both S and P polarization in a device optimized at $\lambda < 1.55~\mu m$.

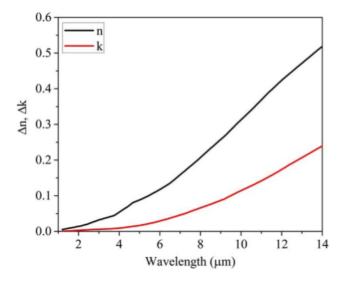


Transmitted Am and Cr intensity versus angle of incidence for a 500 nm GST film thickness at $\lambda < 1.55~\mu m$ using 200 nm N-doped Si contacts.

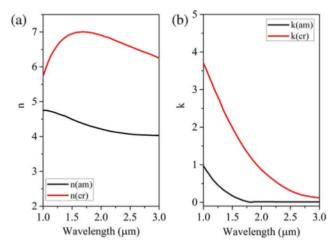


Real and imaginary indexes versus wavelength

N-doped Si:

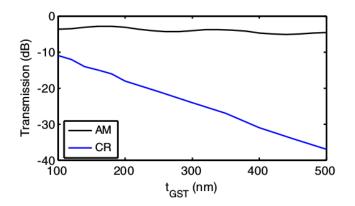


GST:



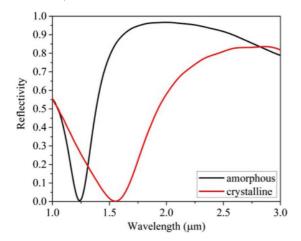
Performance of transmissive SLM

Transmitted Am and Cr intensity versus GST film thickness at $\lambda < 1.55~\mu m$ using 200 nm N-doped Si contacts.

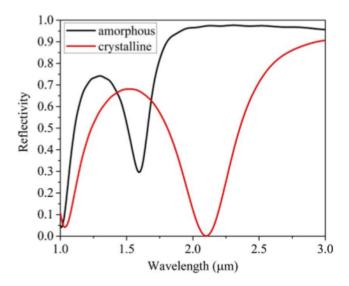


Performance of reflective SLM

Calculated reflectance as a function of wavelength for an EO device optimized at $\lambda < 1.55~\mu m.$



Calculated reflectance as a function of wavelength for an EO device optimized at $\lambda < 2.10~\mu m.$



Related work

Issues

Challenge: Implement a practical and effective technique for electrical addressing and temporal multiplexing of the N \times M array of pixels in the PCM SLM. Solution: We are proposing that the LC addressing structures should be adapted and adopted in the PCM cases of transmissive and reflective SLMs. Commercial devices are available with logic supplies of <3.3 V and >12 V for driving pixels. In the present case, the set and reset pulse amplitudes are about 2 and 5 V, respectively, and the known circuitry can readily provide that.

Speed: For 500 nm thick GST the **reset** pulse du- ration is around **100** ns and the **set** pulse duration is around **1.5** ns, with further reduction in GST thickness leading to faster reset/set times.

Gray scale enhancement: Binary operation is not always sufficient, and a scheme toextend our device performance from binary to gray scale would help to increase the potential application space. We speculate that moderate sized "macro pixels," each composed of multiple individual black/white pixels, could be used for gray-scale production. Furthermore, gray-scale operation may also be obtainable through the stacking of multiple layers of PCMs separated by additional conducting layers within a given pixel. Here, each independent phase change layer could be switched, allowing for multiple (>2) transmission (reflection) value states for a given pixel.

Upper limit thickness: Finally, we note that there is in practice an upper limit on the PCM film thickness t which is determined by the maximum electric

power that is acceptable for addressing a given pixel (the I^2R Joule heating during reset is proportional to t). With this in mind, we have taken $\mathbf{t} = \mathbf{500}$ nm as the upper limit.

References

- Proposal of a small self-holding 2 \times 2 optical switch using phase-change material
- Electro-optical switching at 1550 nm using a two-state GeSe phase-change layer
- Electro-optical 1×2 , $1 \times N$, and $N \times N$ fiber optic and free-space switching over 1.55 to 3.0 μm using a Ge Ge₂Sb₂Te₅ Ge prism structure
- Simulations of silicon-on-insulator channel waveguide electrooptical 2×2 switches and 1×1 modulators using a Ge₂Sb₂Te₅ self-holding layer
- Electro-optic phase-change 2 \times 2 switching using three- and four-waveguide directional couplers
- • Waveguide-size hybrid ${\rm Si-VO_2}$ waveguide electroabsorption optical switches and photodetectors